Impurity	Target concentration [ppm(w)]	Target price [US\$/kg]
Fe	50	5-7
Al	50	
Ca	50	
Ti	5	
С	50	
В	7	
Р	7	
0	200	
Other impurities	Less than 5	

Table 5.4 Metallurgical silicon expected characteris-tics if upgraded with best currently known metallurgicaltechnology

 Table 5.5
 Specification of chemical impurities in lowest-grade silicon currently purchased to produce multicrystalline silicon wafers

Impurity	Specification
Fe, Al, Ca, Ti, metallic impurities	Less than 0.1 ppm(w) each
C	Less than 4 ppm(w)
O	Less than 5 ppm(w)
B	Less than 0.3 ppm(w)
P	Less than 0.1 ppm(w)

Table 5.6Electrical specification of lowest-grade silicon cur-rently purchased to produce multicrystalline silicon wafers

Property	Specification
Resistivity Minority-carrier lifetime	Higher than 1 ohm cm, <i>p</i> -type Higher than 25 μ s

as tentatively indicated in Table 5.4. However, impurity contents, particularly boron and phosphorus, prevent the use of such material in solar cells. The current minimum purity requested for growing multicrystalline silicon ingots for wafering is given in Tables 5.5 and 5.6.

For semiconductor grade silicon, impurity levels are at least at the ppb level and resistivity within 1000 to 30 000 ohm cm. Although purity requirements for solar cells are not as stringent as for semiconductors, the industry has up to now been forced to select its silicon raw material from the semiconductor silicon source. Silicon is one of the main, if not the largest, cost drivers of the installed PV system. It accounts for approximately 25% of the wafer cost and 15% of the cell cost. Taking into account the dominant share of silicon crystalline technology, the industry is very sensitive to the silicon